

L Number	Hits	Search Text	DB	Time stamp
-	251	438/636.ccls.	USPAT	2004/02/02 12:46
-	306	438/634.ccls.	USPAT	2004/02/02 12:33
-	520	438/787.ccls.	USPAT	2004/02/02 12:34
-	134	438/952.ccls.	USPAT	2004/02/02 12:34
-	535	438/725.ccls.	USPAT	2004/02/02 12:37
-	976	438/624.ccls.	USPAT	2004/02/02 12:37
-	680	438/618.ccls.	USPAT	2004/02/02 12:37
-	749	257/750.ccls.	USPAT	2004/02/02 12:38
-	463	257/760.ccls.	USPAT	2004/02/02 12:42
-	183	bao-tien\$.in. jang-syun\$.in.	USPAT	2004/02/02 12:41
-	33	bao-tien\$.in. jang-syun\$.in.	US-PGPUB	2004/02/02 12:41
-	0	bao-tien\$.in. jang-syun\$.in.	EPO; JPO; DERWENT; IBM_TDB	2004/02/02 12:41
-	5177	(anti\$reflective \$reflective antirefl\$9 reflect\$9) and (resist photoresist) and (silicon adj oxide)	USPAT	2004/02/02 12:45
-	1013	((anti\$reflective \$reflective antirefl\$9 reflect\$9) and (resist photoresist) and (silicon adj oxide)) and ((anti\$reflective \$reflective antirefl\$9 reflect\$9) same (silicon adj oxide))	USPAT	2004/02/02 12:46
-	2752	(anti\$reflective \$reflective antirefl\$9 reflect\$9) and (resist photoresist) and (silicon adj oxide)	US-PGPUB	2004/02/02 12:46
-	512	((anti\$reflective \$reflective antirefl\$9 reflect\$9) and (resist photoresist) and (silicon adj oxide)) and ((anti\$reflective \$reflective antirefl\$9 reflect\$9) same (silicon adj oxide))	US-PGPUB	2004/02/02 12:46